· · · · · · · · · · · · · · · · · · ·	Application No.	Applicant(s)
Notice of Allowability	10/773,879	CHRYSLER ET AL.
	Examiner	Art Unit
	David Nhu	2818
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>11/18/04</u> .		
2. The allowed claim(s) is/are <u>28,30 and 32-35.</u>		
3. \boxtimes The drawings filed on <u>2/6/04</u> are accepted by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 09/920,275. 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements 		
noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
6. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.	
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
ldentifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s)		
1. Motice of References Cited (PTO-892)	_	Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Da	
 Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date <u>07</u> Examiner's Comment Regarding Requirement for Deposit 	7. ☐ Examiner's Amend8. ☑ Examiner's Statem	
of Biological Material	9. [] Other	

Application/Control Number: 10/773,879

Art Unit: 2818

REASONS FOR ALLOWANCE

1. Claims 28,30, 32-35 are allowed.

- 2. The following is an examiner's statement of reasons for allowance: None of the references of record teaches or suggests in claims 28, 32: forming a first combination wafer having a support layer and a layer of solid diamond on the support layer; forming a second combination wafer by implanting ions into a surface of a monocrystalline semiconductor material; forming a third combination wafer by attaching the first combination wafer to the second combination wafer; shearing a portion of the monocrystalline wafer not implanted with the ions, the portion of the monocrystalline semiconductor material implanted with the ions forming a layer of monocrystalline semiconductor material on the layer of solid diamond (as cited in claim 28); bonding a side of the monocrystalline semiconductor material through which the ions are implanted to the layer of material; severing a portion of the monocrystalline semiconductor material from a final portion thereof that is bonded to the layer of material; forming an epitaxial layer of semiconductor material on the monocrystalline semiconductor material; forming a pl;urality of integrated circuits in and on the epitaxial layer, to form a combination wafer; and servering the combination wafer between the integrated circuits to singulate dice of the combination wafer from one another (as cited in claim 32).
- 3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Page 2

Application/Control Number: 10/773,879

Art Unit: 2818

CONCLUSION

4. The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure: Ravi (5,131,963): Silicon on Insulator Semiconductor Composition Conataining

Thin Synthetic Diamond.

5. Any inquiry concerning this communication on earlier communications from the examiner

should be directed to David Nhu, (571)272-1792. The examiner can normally be reached

on Monday-Friday from 7:30 AM to 5:00 PM.

The examiner's supervisor, David Nelms can be reached on (571)272-1787.

The fax phone number for the organization where this application or proceeding is assigned is

(703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should

be directed to the receptionist whose telephone number is (703) 308-0956

David Nhu

December 13, 2004

Page 3